Application/Control No. O9/827,056 Examiner Thomas J. Mage Applicant(s)/Patent Under Reexamination LIU ET AL. Page 1 of 1

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*		Document Number Country Code-Number-Kind Code	Date MM-YYYY	Name	Classification
	Α	US-6,355,527	03-2002	Yai-Fen Lin et al.	438/265
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Notice of References Cited

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O9/827,056

Examiner

Thomas J. Magee

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